

L Number	Hits	Search Text	DB	Time stamp
1	121	(((second adj4 power) with electrode\$1) and ((uniformity or uniform) with etch\$3)) not (((etch\$3 same ((rectangular or rectangle or square) with (substrate\$1 or wafer\$1))) and ((uniformity or uniform) with etch\$3)) and ((second adj4 power) or (second adj4 electrode)))) and ((plasma or dry) with etch\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/09/26 09:23

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L Number	Hits	Search Text	DB	Time stamp
46	17	(((((second adj4 power) with electrode\$1) and ((uniformity or uniform) with etch\$3)) not (((etch\$3 same ((rectangular or rectangle or square) with (substrate\$1 or wafer\$1))) and ((uniformity or uniform) with etch\$3)) and ((second adj4 power) or (second adj4 electrode)))) and ((plasma or dry) with etch\$3)) and (plurality with power) and (plurality with electrodes)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/09/26 14:17

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